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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.
10/637,664	08/11/2003	Makoto Izumi	57810-072 3514	
7590 12/01/2004			EXAMINER	
McDERMOTT, WILL & EMERY			BREWSTER, WILLIAM M	
600 13th Street, N.W. Washington, DC 20005-3096			ART UNIT	PAPER NUMBER
,			2823	

DATE MAILED: 12/01/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

			<u> </u>			
Office Action Summary		Application No.	Applicant(s)			
		10/637,664	IZUMI ET AL.			
		Examiner	Art Unit			
		William M. Brewster	2823			
Period fo	The MAILING DATE of this communication appears on the cover sheet with the correspondence address Period for Reply					
THE I - Exter after - If the - If NO - Failu	ORTENED STATUTORY PERIOD FOR REPLY MAILING DATE OF THIS COMMUNICATION. nsions of time may be available under the provisions of 37 CFR 1.13 SIX (6) MONTHS from the mailing date of this communication. period for reply specified above is less than thirty (30) days, a reply repriod for reply is specified above, the maximum statutory period we to reply within the set or extended period for reply will, by statute, reply received by the Office later than three months after the mailing and patent term adjustment. See 37 CFR 1.704(b).	36(a). In no event, however, may a reply be timed within the statutory minimum of thirty (30) days will apply and will expire SIX (6) MONTHS from a cause the application to become ABANDONE	nely filed s will be considered timely. the mailing date of this communication. D (35 U.S.C. § 133).			
Status			•			
1)⊠	Responsive to communication(s) filed on 02 No	ovember 2004				
	This action is FINAL . 2b) This action is non-final.					
	, _					
- / 😀	closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11, 453 O.G. 213.					
Dispositi	on of Claims					
4)⊠	4)⊠ Claim(s) <u>1-21</u> is/are pending in the application.					
-	4a) Of the above claim(s) <u>13-21</u> is/are withdrawn from consideration.					
	Claim(s) is/are allowed.					
· · · —	Claim(s) <u>1-12</u> is/are rejected.					
	Claim(s) is/are objected to. Claim(s) are subject to restriction and/or election requirement.					
Applicati	on Papers					
9)□	The specification is objected to by the Examine	r				
-	10)⊠ The drawing(s) filed on <u>02 November 2004</u> is/are: a)⊠ accepted or b)□ objected to by the Examiner.					
يكاره.						
	Applicant may not request that any objection to the drawing(s) be held in abeyance. See 37 CFR 1.85(a).					
11)	Replacement drawing sheet(s) including the correction is required if the drawing(s) is objected to. See 37 CFR 1.121(d). 11) The oath or declaration is objected to by the Examiner. Note the attached Office Action or form PTO-152					
Priority u	ınder 35 U.S.C. § 119					
12)	Acknowledgment is made of a claim for foreign	priority under 35 U.S.C. § 119(a)	H-(d) or (f).			
a) ☐ All b) ☐ Some * c) ☐ None of:						
/-	1. Certified copies of the priority documents have been received.					
	Certified copies of the priority documents have been received in Application No					
	3. Copies of the certified copies of the priority documents have been received in this National Stage.					
	application from the International Bureau	•	o in the National Otage,			
* See the attached detailed Office action for a list of the certified copies not received.						
		,				
Attachmen	t(s)					
1) Notice of References Cited (PTO-892) 4) Interview Summary (PTO-413)						
2) Notic	ite					
3) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 5) Notice of Informal Patent Application (PTO-152) 6) Other:						

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DETAILED ACTION

The following rejection has been incorporated by reference from the non-final rejection, and is represented here for convenience:

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 1-9 are rejected under 35 U.S.C. 103(a) as being unpatentable over Atsushi, JP Publication No. 10-229180 in view of DiLoreto et al., U.S. Patent No. 6,076,933.

Atsushi teaches a solid state image device comprising: in fig. 2, an optical lens 24; a solid state image sensor 16, 17 including a microlens 22; and a layer 19 (a light filter) formed between said optical lens and said microlens of said solid state image sensor, p. 4, ¶ 22;

limitations from claim 2: in fig. 2, wherein said optical lens and said microlens of said solid state image sensor are integrally formed through said layer, p. 4, ¶ 22; limitations from claims 4, 5, 6: wherein said microlens of said solid state image sensor includes: a first film having an upwardly projecting shape, and a second film, formed on said first film, having an upwardly projecting shape reflecting said

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upwardly projecting shape of said first film; wherein said first film and said second film are made of materials having the same refractive index; wherein said first film and said second film are formed by SiN films (film 22 formed from the original layer 21 SiN), p. 4, ¶ 22; in fig. 2, wherein examiner interprets 22 as having two layers of the same refractive index wherein the boundary is not shown between them;

limitations from claim 3: with said microlens of said solid state image sensor has a refractive index of 2.0;

limitations from claims 7-8, in fig. 2, wherein said first film is formed with a plurality of said upwardly projecting shapes at prescribed intervals, peaks of 22, and said second film 18 is formed with a plurality of said upwardly projecting shapes to fill up gaps of said first film; wherein each adjacent pair of said upwardly projecting shapes of said second film are connected with each other to include no substantially flat region on the boundary therebetween.

Atsushi does not specify whether the layer between the optical lens and the microlens contains resin, but rather specifies it is an image filter. DiLoreto teaches an image filter with resin. DiLoreto teaches in figs. 4-6, an image filter with resin 62, col. 7, lines 17-27, wherein image filter contains a refractive index of approximately 1.5, col. 7, line 56-col. 8, line 12. DiLoreto gives motivation in col. 2, lines 28-45. It would have been obvious to a person of ordinary skill in the art at the time the invention was made.

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to recognize that combining DiLoreto's process with Atsushi's invention would have been beneficial because it provides improved optical properties.

For claim 9, Atsushi does not specify the thickness of the second film, but the practitioner may optimize this dimension.

"Normally, it is to be expected that a change in temperature, or in concentration, or in both, would be an unpatentable modification. Under some circumstances, however, changes such as these may impart patentability to a process if the particular ranges claimed produce a new and unexpected result which is different in kind and not merely degree from the results of the prior art . . . such ranges are termed 'critical ranges' and the applicant has the burden of proving such criticality . . . More particularly, where the general conditions of a claim are disclosed in the prior art, it is not inventive to discover the optimum or workable ranges by routine experimentation."

In re Aller 105 USPQ 233, 255 (CCPA 1955). See also In re Waite 77 USPQ 586 (CCPA 1948); In re Scherl 70 USPQ 204 (CCPA 1946); In re Irmscher 66 USPQ 314 (CCPA 1945); In re Norman 66 USPQ 308 (CCPA 1945); In re Swenson 56 USPQ 372 (CCPA 1942); In re Sola 25 USPQ 433 (CCPA 1935); In re Dreyfus 24 USPQ 52 (CCPA 1934).

Note that the specification contains no disclosure of either the critical nature of the claimed dimensions of any unexpected results arising there from. Where patentability is aid to be based upon particular chosen dimensions or upon another variable recited in a claim, the Applicant must show that the chosen dimensions are critical. In re Woodruff, 919 F.2d 1575, 1578, 16 USPQ2d 1934, 1936 (Fed. Cir. 1990).

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Claims 10-11 are rejected under 35 U.S.C. 103(a) as being unpatentable over Atsushi in view of DiLoreto as applied to claims 1-9 above, and further in view of Needham.

Needham teaches the solid state image device according to claim 1, fig. 6, further comprising a recessed third film 18 formed on said solid state image sensor, wherein said microlens of said solid state image sensor includes a fourth film 20, embedded in the recessed portion of said third film, SiO₂, exhibiting a larger refractive index than said third film and having a downwardly projecting shape; wherein said fourth film is formed by an SiN film. Needham gives motivation in the Abstract. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to recognize that combining Atsushi's and DiLoreto's process with Needham's invention would have been beneficial because it improves the quantum efficiency.

Claims 12 are rejected under 35 U.S.C. 103(a) as being unpatentable over Atsushi in view of DiLoreto and Needham as applied to claims 1-11 above, and further in view of Wolf, V. II, p. 229-232.

Atsushi, DiLoreto, and Needham do not specify the use of SOG. Needham does specify the use oxide for the third layer, but does not specify SOG. Wolf specifies using SOG for an oxide layer and gives motivation in p. 229, bottom ¶. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to recognize that combining Wolf's process with Atsushi, DiLoreto, and Needham's

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invention would have been beneficial because it has simpler processing and lower defect density.

Response to Arguments

Applicant's arguments filed 2 November 2004 have been fully considered but they are not persuasive. Applicant argues Atsushi teaches an optical lens, but fails to teach a microlens and that a microlens is different from an optical lens.

Examiner respectfully disagrees, and proffers that Atsushi does teach a microlens. On p. 4, ¶ 22, last sentence states, "furthermore, the 2nd micro lens 24 which comes to process this 2nd lens formation film 23 is formed in the upper part of the 2nd lens formation film 23 above the 1st micro lens 22 (incidence side of incident light L)." Indeed the term 'micro lens' is used. Furthermore, the existence of the microlenses within the device also proffers evidence against applicant's argument that the lenses of Atsushi do not condense light 'inside' the solid state image device. While there may be some differences between the application's specification and the prior art of record, the USPTO tasks the examiner with interpreting the claims broadly.

Examiner must give claims their broadest reasonable interpretation, MPEP §2111, "During patent examination, the pending claims must be 'given the broadest reasonable interpretation consistent with the specification.' Applicant always has the opportunity to amend the claims during prosecution and broad interpretation by the examiner reduces the possibility that the claim, once issued, will be interpreted more broadly than is justified, *In re Pratter*, 415 F.2d 1393, 1404-05, 162 USPQ 541, 550-51

(CCPA 1969), *In re Morris*, 127 F.3d 1048, 1054-55, 44 USPQ2d 1023, 1027-28 (Fed. Cir. 1997)." Also see *In re Zletz*, 13 USPQ 2d. 1320 (Fed. Cir. 1989).

For these reasons, the rejection is proper.

Conclusion

THIS ACTION IS MADE FINAL. Applicant is reminded of the extension of time policy as set forth in 37 CFR 1.136(a).

A shortened statutory period for reply to this final action is set to expire THREE MONTHS from the mailing date of this action. In the event a first reply is filed within TWO MONTHS of the mailing date of this final action and the advisory action is not mailed until after the end of the THREE-MONTH shortened statutory period, then the shortened statutory period will expire on the date the advisory action is mailed, and any extension fee pursuant to 37 CFR 1.136(a) will be calculated from the mailing date of the advisory action. In no event, however, will the statutory period for reply expire later than SIX MONTHS from the mailing date of this final action.

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to William M. Brewster whose telephone number is 571-272-1854. The examiner can normally be reached on Full Time.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Olik Chaudhuri can be reached on 571-272-1855. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

17 November 2004 WB

Olik Charribath
Supervisory Palant Supervisory

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Technology Center 2800